

List of Publications of Dr. Manodipan Sahoo,  
Associate professor, Department of Electronics Engineering, IIT(ISM), Dhanbad

International Journals – 26  
International Conferences- 35  
National Conference/Symposium- 5  
Books/Book Chapters - 3  
Total Publications- 69

Webpage: <https://sites.google.com/view/nanolab-iitdhanbad>

Book and Book Chapter:

1. Published a Book on "**Modelling and Simulation of CNT and GNR Interconnects**" in Lambert Academic Publishers (**2019**).
2. Published a Book Chapter on "**Modelling Interconnects for Future VLSI Circuit Applications**" in IET Book entitled "**VLSI and Post-CMOS Electronics: Devices, Circuits and Interconnects**" (**2019**), DOI: [10.1049/PBCS073G](https://doi.org/10.1049/PBCS073G).
3. Published a Book Chapter on "**Hybrid Cu-Carbon as Interconnect Materials and Their Interconnect Models**" in the Book entitled "**Nano-Interconnect Materials and Models for Next Generation Integrated Circuit Design**" (CRC Press, **2023**).

International Journals:

**J26.** S. Bardhan, **M. Sahoo**, J. Samanta, and H. Rahaman, "A Quasi-Ballistic Model For Short Channel Monolayer Graphene Field Effect Transistor Including Scattering Effects", IETE Journal of Research, Taylor and Francis Publishers, 2024, DOI: [10.1080/03772063.2024.2352154](https://doi.org/10.1080/03772063.2024.2352154).

**J25.** N. K. Singh, and **M. Sahoo**, "Comparative Investigation of Different Doping Techniques in TMD Tunnel FET for Subdeca Nanometer Technology Nodes", Journal of Electronic Materials, May, 2023, DOI:10.1007/s11664-023-10505-8, Link: <https://rdcu.be/ddEh2>.

**J24.** S. K. Dora, H. B. Mishra, **M. Sahoo**, "Low Complexity Implementation of OTFS Transmitter using Fully Parallel and Pipelined Hardware Architecture", Journal of Signal Processing Systems, pg. 1-10, 2023, DOI: <https://doi.org/10.1007/s11265-023-01847-x>.

**J23.** M. Kumari, N. K. Singh and **M. Sahoo**, "A detailed investigation of dielectric-modulated dual-gate TMD FET based label-free biosensor via analytical modelling", Nature Scientific Reports, 12:21115, 2022, DOI: <https://doi.org/10.1038/s41598-022-24677-6>, Link for the paper: <https://rdcu.be/c09jE>.

**J22.** B. Kumari, R. Y. Sharma and **M. Sahoo**, "Electro-Thermal Modeling and Reliability Analysis of Cu-Carbon Hybrid Interconnects for Beyond-CMOS Computing", Applied Physics Letters, 2022, DOI: <https://doi.org/10.1063/5.0101329>.

**J21.** N. K. Singh, M. Kumari and **M. Sahoo**, "All Region Analytical Modeling of 2-D Transition Metal Dichalcogenide FET by Considering effect of Fringing field and Region-wise Mobility", *Physica E: Low-dimensional Systems and Nanostructures*, 2022, DOI: <https://doi.org/10.1016/j.physe.2022.115480>.

**J20.** B. Kumari, P. Santosh, R. Y. Sharma and **M. Sahoo**, "Thermal-Aware Modeling and Analysis of Cu-Mixed CNT Nanocomposite Interconnects", *IEEE Transactions on Nanotechnology*, vol. 21, pp. 163-171, IEEE Publishers, DOI: 10.1109/TNANO.2022.3160870.

**J19.** B. Kumari, R. Y. Sharma and **M. Sahoo**, "Performance and Reliability Improvement in Intercalated MLGNR Interconnects using Optimized Aspect Ratio ", *Nature Scientific Reports*, 12:1475 (2022), DOI: 10.1038/s41598-022-05222-x, Link: <https://rdcu.be/cFOQT>.

**J18.** N. K. Singh and **M. Sahoo**, "Analytical Modeling of Short-Channel TMD TFET Considering Effect of Fringing Field and 2-D Junctions Depletion Regions", *IEEE Transactions on Electron Devices*, IEEE Publishers, February, 2022, vol. 69, no. 2, pp. 843-850, DOI: [10.1109/TED.2021.3135367](https://doi.org/10.1109/TED.2021.3135367).

**J17.** B. Kumari, R. Kumar, R. Y. Sharma and **M. Sahoo**, "Design, Modeling and Analysis of Cu-Carbon Hybrid Interconnects", *IEEE Access*, IEEE Publishers, vol. 9, pp. 113577 – 113584, DOI: [10.1109/ACCESS.2021.3104299](https://doi.org/10.1109/ACCESS.2021.3104299), 2021.

**J16.** M. Kumari, N. K. Singh, M. Sahoo and H. Rahaman, "2-D Analytical Modeling and Simulation of Dual Material, Double Gate, Gate Stack engineered, Junctionless MOSFET based Biosensor with Enhanced Sensitivity", *Silicon*, Springer, July, 2021, pp. 1-12, DOI: <https://doi.org/10.1007/s12633-021-01223-z>

**J15.** M. Kumari, N. K. Singh, M. Sahoo and H. Rahaman, "Work function optimization for Enhancement of sensitivity of Dual Material(DM), Double gate(DG), Junctionless MOSFET based biosensor", *Applied Physics A*, Springer, January, 2021, DOI: <https://doi.org/10.1007/s00339-020-04256-0>.

**J14.** N. K. Singh, M. Kumari and M. Sahoo, "A Compact Short-Channel Analytical Drain Current Model of Asymmetric Dual-gate TMD FET in Subthreshold Region including Fringing Field effects", *IEEE Access*, IEEE Publishers, November, 2020, vol. 8, no. 11, pp. 207982-207990, DOI: [10.1109/ACCESS.2020.3038421](https://doi.org/10.1109/ACCESS.2020.3038421).

**J13.** N. K. Singh and M. Sahoo, "Investigation on the Effect of Gate dielectric and other Device parameters on Digital Performance of Silicene Nanoribbon Tunnel FET", *IEEE Transactions on Electron Devices*, IEEE Publishers, July, 2020, vol. 67, no. 7, pp. 2966-2973, DOI: [10.1109/TED.2020.2992016](https://doi.org/10.1109/TED.2020.2992016).

**J12.** B. Kumari, and **M. Sahoo**, `` Performance and Signal Integrity Analysis of Intercalation Doped Multilayer Vertical Graphene Nanoribbon Interconnects", *IET Circuits, Devices and Systems*, IET Publishers 2019, DOI: <https://doi.org/10.1049/iet-cds.2019.0072>.

**J11.** S. Bardhan, **M. Sahoo** and, H. Rahaman, ``A Boltzmann Transport Equation Based Semiclassical Drain Current Model for Bilayer GFET Including Scattering Effects," IET Circuits, Devices and Systems, *IET Publishers* 2019, DOI: <https://doi.org/10.1049/iet-cds.2018.5104>.

**J10.** B. Kumari and **M. Sahoo**, `` Stability Analysis of Multilayer Vertical Graphene Nanoribbon Interconnects", IOP Science, Materials Research Express, DOI:<https://iopscience.iop.org/article/10.1088/2053-1591/ab1b92>, vol. 6, pp. 08560, 2019.

**J9.** B. Kumari and **M. Sahoo**, ``Performance and Power Optimization for Intercalation doped Multilayer Graphene Nanoribbon Interconnects", IETE Journal of Research, *Taylor and Francis Publishers*, 2019.

DOI: <https://doi.org/10.1080/03772063.2019.1621214>

**J8.** S. Bardhan, **M. Sahoo** and, H. Rahaman, `` Empirical Drain Current Model of Graphene Field-Effect Transistor for Application as a Circuit Simulation Tool," IETE Journal of Research, *Taylor and Francis Publishers*, 2019, DOI: <https://doi.org/10.1080/03772063.2019.1620639>

**J7.** S. Bardhan, **M. Sahoo** and, H. Rahaman, ``A Surface Potential Based Model for Dual Gate Bilayer GFET Including the Capacitive Effects", *Journal of Circuits, Systems and Computers*,*World Scientific Publishers*. <https://doi.org/10.1142/S0218126619502414>, 2019.

**J6.** **M. Sahoo**, and H. Rahaman, "Analysis of Crosstalk Induced Effects in Multilayer Graphene Nanoribbon Interconnects", *Journal of Circuits, Systems, and Computers*, *World Scientific Publishers*, Vol. 26, No. 6 (2017) 1750102, pp. 1-21, <https://doi.org/10.1142/S021812661750102X>, 2017.

**J5.** **M. Sahoo**, and H. Rahaman, "Modeling and Analysis of Crosstalk Induced Overshoot/Ubershoot Effects in Multilayer Graphene Nanoribbon Interconnects and Its Impact on Gate Oxide Reliability", *Microelectronics Reliability* (2016), Elsevier Publishers, [Vol.63](#), August 2016, pp. 231–238, <https://doi.org/10.1016/j.microrel.2016.06.017>.

**J4.** **M. Sahoo**, P. Ghosal, and H. Rahaman, "Modeling and Analysis of Crosstalk Induced Effects in Multiwalled Carbon Nanotube Bundle Interconnects: An ABCD Parameter Based Approach", *IEEE Transactions on Nanotechnology*, *IEEE*, Vol. 14, no. 2, pp. 259–274, March 2015, <https://doi.org/10.1109/TNANO.2014.2388252>.

**J3.** **M. Sahoo**, and H. Rahaman, "Modeling of Crosstalk Induced Effects in Copper-Based Nanointerconnects: An ABCD Parameter Matrix-Based Approach", *Journal of Circuits, Systems, and Computers*, *World Scientific Publishers*, Vol. 24, no. 2, pp. 1-22, 2015, <https://doi.org/10.1142/S0218126615400071>.

**J2.** **M. Sahoo**, P. Ghosal, and H. Rahaman, "Performance Modeling and Analysis of Carbon Nanotube Bundles for Future VLSI Circuit Applications", *Journal of Computational Electronics*, Springer Publications, Vol. 13, no. 3, pp. 673-688, 2014, <https://doi.org/10.1007/s10825-014-0587-7>.

**J1.** **M. Sahoo**, H. Rahaman, and Bhargab B. Bhattacharya, "On the Suitability of Single-Walled Carbon Nanotube Bundle Interconnects for High-Speed and Power-Efficient Applications", *Journal of Low Power Electronics*, American Scientific Publishers, Vol. 10, no. 3, pp. 191-206, September 2014, <https://doi.org/10.1166/jolpe.2014.133>.

International Conferences:

**C35.** M. Kumari, and **M. Sahoo**, "Sensitivity Enhancement of TMD MOSFET-Based Biosensor by Modeling and Optimization of Back Gate Parameters", IEEE VLSID, January 2024, DOI: [10.1109/VLSID60093.2024.00007](https://doi.org/10.1109/VLSID60093.2024.00007).

**C34.** S. K. Dora, H. B. Mishra, M. Sahoo and K. Yadav, "Hardware Implementation of OTFS Modulation Using CORDIC Algorithm", IEEE SPCOM (Accepted).

**C33.** M. Kumari, and **M. Sahoo**, "Sensitivity Enhancement of TMD MOSFET-Based Biosensor by Optimization of Back Gate Parameters and Noise Analysis", IEEE CODEC, December 2023, DOI: [10.1109/CODEC60112.2023.10466064](https://doi.org/10.1109/CODEC60112.2023.10466064).

**C32.** S. K. Dora, R. K. Yadav, **M. Sahoo** and H. B. Mishra, "VLSI Architecture for Low Complexity Zero Forcing Equalizer in OTFS Modulation", IEEE ELEXCOM, August 2023, DOI: [10.1109/ELEXCOM58812.2023.10370165](https://doi.org/10.1109/ELEXCOM58812.2023.10370165).

**C31.** N. K. Singh, R. Shankar, S. Verma, and **M. Sahoo**, "Design of low-power and high-performance 10 nm SRAM using Electrostatically doped TMD TFET", IEEE ISDCS 2023, May, 2023, pp. 1-6, DOI: [10.1109/ISDCS58735.2023.10153525](https://doi.org/10.1109/ISDCS58735.2023.10153525).

**C30.** M. Kumari, and **M. Sahoo**, "Impact of Process Induced Strain on the Sensitivity of Charge Plasma Doped TMD TFET Biosensor", 6<sup>th</sup> IEEE ICEE, Bangalore, December, 2022, pp. 1-6, DOI: [10.1109/ICEE56203.2022.10118170](https://doi.org/10.1109/ICEE56203.2022.10118170).

**C29.** B. Kumari, R. Sharma and **M. Sahoo**, "Stability Analysis of Nanoscale Copper-Carbon Hybrid Interconnects", IEEE ECTC, pp. 1-6, July 2022, DOI: [10.1109/ECTC51906.2022.00158](https://doi.org/10.1109/ECTC51906.2022.00158).

**C28.** B. Kumari, S. Pandranki, **M. Sahoo**, R. Sharma, "Copper-MWCNT Composite: A Solution to Breakdown in Copper Interconnects", 2021 IEEE 21<sup>st</sup> International Conference on Nanotechnology, July 2021, DOI: [10.1109/NANO51122.2021.9514276](https://doi.org/10.1109/NANO51122.2021.9514276).

**C27.** B. Kumari, R. Kumar, **M. Sahoo** and R. Sharma, "Performance Analysis of Self Heated Multilayer Vertical Graphene Nanoribbon Interconnects", Proceedings of the 71<sup>st</sup> IEEE Electronic Components and Technology Conference, Lake Buena Vista, May 2021, DOI: [10.1109/ECTC32696.2021.00256](https://doi.org/10.1109/ECTC32696.2021.00256).

**C26.** P. Howladar, K. Mondal, **M. Sahoo**, "Machine Learning based Supraventricular Tachycardia Detection Model of ECG signal", International Conference on Data Analytics & Management, Jaipur, June, 2021 (**Got Best Paper award**).

**C25.** P. Howladar, **M. Sahoo**, "Machine Learning based Ventricular Tachycardia Detection of ECG Signal", 8th International Conference on Microelectronics, Circuits & Systems, Kolkata, May, 2021 (**Got Best Paper award**).

**C24.** R. Kumar, B. Kumari, S. Kumar, **M. Sahoo** and R Y. Sharma, "Temperature and Dielectric Surface Roughness dependent Performance Analysis of Cu-Graphene Hybrid Interconnects", *Proceedings of the IEEE Electrical Design of Advanced Packaging and Systems (EDAPS)*, Shenzhen, China, December 2020.

**C23.** K. Sable and **M. Sahoo**, ``Electrical and Thermal Analysis of Cu-CNT Composite TSV and GNR Interconnects", Accepted in *International Symposium on Devices, Circuits and Systems (ISDCS)*, Howrah, March, 2020.

**C22.** N. K. Singh and **M. Sahoo**, ``Investigation of Silicene Nanoribbon Tunnel FET for Low power Digital VLSI circuit application with variation of Device parameters", Accepted in X International Conference on Communication, Circuits and Systems (ICCCAS, 2018) held in Chengdu, China during December 22-24, 2018.

**C21.** P. Jha, B. Kumari and **M. Sahoo**, ``Investigation on the Impact of Various Intercalation doping on the Signal Integrity in ML-GNR Interconnects", Accepted in X International Conference on Communication, Circuits and Systems (ICCCAS, 2018) held in Chengdu, China during December 22-24, 2018.

**C20.** B. Kumari and **M. Sahoo**, ``Width Optimization of Intercalation doped Multilayer Graphene Nanoribbon Interconnects", 2018 *International Symposium on Devices, Circuits and Systems (ISDCS)*, Howrah, 2018, pp. 1-5, <https://doi.org/10.1109/ISDCS.2018.8379653>.

**C19.** B. Kumari and **M. Sahoo**, ``Thickness Optimization of Intercalation doped Multilayer Graphene Nanoribbon Interconnects", IEEE ICDCS-2018, March, 2018.

**C18.** M. Kumari, **M. Sahoo** and J. Kumar, ``Modelling and Optimization of Double barrier AlGaAs/GaAs/AlGaAs Resonant Tunneling Diode for THz applications", Accepted in 4<sup>th</sup> IEEE ICEE, 2018 to be held in Bangalore in December, 2018 (**Got Best Poster award**).

**C17.** **M. Sahoo**, and H. Rahaman, "Impact of Mutual Inductance on the Crosstalk Induced Effects in Single-Walled Carbon Nanotube Bundle Interconnects", *IEEE ICDCS*, Karunya University, 2016, pp. 286-290,

<https://doi.org/10.1109/ICDCSyst.2016.7570585>

**C16.** S. Bardhan, **M. Sahoo** and H. Rahaman, ``Analytical Study of BTE Based Multilayer GFET Model", MicroCom 2016, NIT Durgapur, 2016, pp. 1-6, <https://doi.org/10.1109/MicroCom.2016.7522594>.

**C15.** S. Bardhan, **M. Sahoo** and H. Rahaman, ``A Verilog-A based Semiclassical Model for Dual Gated Graphene Field-Effect Transistor'', *IEEE ICDCS*, Karunya University, 2016, pp. 37-42, <https://doi.org/10.1109/ICDCSyst.2016.7570619>

**C14. M. Sahoo** and H. Rahaman, "Modeling of Crosstalk induced Overshoot/Uundershoot effects in Multilayer Graphene Nanoribbon Interconnects", *IEEE EICT*, Khulna University, December, 2015, pp. 416-421, <https://doi.org/10.1109/EICT.2015.7391988>.

**C13.** S. Bardhan, **M. Sahoo** and H. Rahaman, ``Analytical Drain Current Model for Graphene Metal-Oxide semiconductor Field-Effect Transistor'', *IEEE EICT*, Khulna University, December, 2015, pp. 422-427, <https://doi.org/10.1109/EICT.2015.7391989>.

**C12. M. Sahoo**, P. Ghosal, and H. Rahaman, "An ABCD Parameter Based Modeling and Analysis of Crosstalk Induced Effects in Multiwalled Carbon Nanotube undle Interconnects", *IEEE 27<sup>th</sup> International Conference on VLSI Design*, IIT Bombay, India, pp. 433-438, Jan. 5–9, 2014, <https://doi.org/10.1109/VLSID.2014.81>.

**C11. M. Sahoo**, and H. Rahaman, "Modeling of Crosstalk Induced Effects in Nanoscale Copper Interconnects", *IEEE EICT*, KUET, Bangladesh, pp. 1–6, Feb. 13–15, 2014, <https://doi.org/10.1109/EICT.2014.6777811>.

**C10. M. Sahoo**, and H. Rahaman, "An ABCD Parameter Based Modeling and Analysis of Crosstalk Induced Effects in Multilayer Graphene Nano Ribbon Interconnects", *IEEE ISCAS*, Melbourne, Australia, pp. 1138-1142, June 1–5, 2014, <https://doi.org/10.1109/ISCAS.2014.6865341>.

**C9. M. Sahoo**, and H. Rahaman, "Impact of Line resistance variations on Crosstalk delay and noise in Multilayer Graphene Nano Ribbon Interconnects", *5<sup>th</sup> IEEE International Symposium on Electronic System Design (ISED 2014)*, NITK Surathkal, India, pp. 94–98, Dec. 15–17, 2014, <https://doi.org/10.1109/ISED.2014.27>.

**C8.** S. A. Mandal, S. Pal, **M. Sahoo**, P. Mondal and H. Rahaman, ``A New Feedback Circuit Based Charge-pump for a Wide-range and Low-jitter DLL suitable for PET Imaging Applications'', *Proceedings of IEEE ICDCS*, India, 2014, pp. 1-5, <https://doi.org/10.1109/ICDCSyst.2014.6926125>.

**C7.** S. Chakraborty, **M. Sahoo** and H. Rahaman, ``A 1.8 V 64.9 uW 54.1 dB SNDR 1st Order Sigma-Delta Modulator Design Using Clocked Comparator Based Switched Capacitor Technique'', *IEEE Asia Symposium and Exhibit on Quality Electronic Design (ASQED)*, 2013, pp. 220-226, <https://doi.org/10.1109/ASQED.2013.6643591>.

**C6. M. Sahoo**, P. Ghosal, and H. Rahaman, "An ABCD Parameter Based Modeling and Analysis of Crosstalk Induced Effects in Single-Walled Carbon Nanotube Bundle Interconnects", *IEEE/ACM Asia Symposium and Exhibit on Quality Electronic Design (ASQED)*, Penang, Malaysia, pp. 264-273, Aug. 26–28, 2013, <https://doi.org/10.1109/ASQED.2013.6643598>.

**C5. M. Sahoo**, and H. Rahaman, "Modeling of Crosstalk Delay and Noise in Single-walled Carbon Nanotube Bundle Interconnects", *IEEE INDICON*, IIT Bombay, India, pp.

1–6, Dec. 13–15, 2013, <https://doi.org/10.1109/INDCON.2013.6725907>. ([Got Best Paper Award](#))

**C4. M. Sahoo**, H. Rahaman and B. B. Bhattacharya, "Impact of Inductance on the Performance of Single Walled Carbon Nanotube Bundle Interconnects", 4<sup>th</sup> IEEE International Symposium on Electronic System Design (ISED), NTU, Singapore, pp. 16- 20, Dec. 12–13, 2013,<https://doi.org/10.1109/ISED.2013.10>.

**C3. M. Sahoo** and H. Rahaman, "Performance Analysis of Multiwalled Carbon Nanotube Bundles", 33<sup>rd</sup> IEEE International Scientific Conference Electronics and Nanotechnology (ELNANO), NTUU, Ukraine, pp. 200-204, Apr. 16–19, 2013, <https://doi.org/10.1109/ELNANO.2013.6552004>.

**C2. M. Sahoo**, P. Ghosal, and H. Rahaman, "Efficient and Compact Electrical Modeling of Multi Walled Carbon Nanotube Interconnects", 3<sup>rd</sup> IEEE International Symposium on Electronic System Design (ISED), Bengal Engineering and Science University, Shibpur Howrah, India, pp. 236-240, Dec. 19–22, 2012, <https://doi.org/10.1109/ISED.2012.24>.

**C1.** S. A. Kannan, **M. Sahoo**, S. Dwivedi, B. Amrutur and N. Bhat, ``Optimal Power and Noise Allocation for Analog and Digital Sections of a Low Power Radio Receiver", ACM/IEEE ISLPED, India, August, 2008, pp. 271-276, <https://doi.org/10.1145/1393921.1393993>.

#### National Conferences/Symposium:

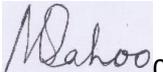
**NC5.** B. Kumari and **M. Sahoo**, ``Impact of Width on the Performance of Intercalation Doped MLGNR Interconnects", INUP Familiarization workshop, IISc, Bangalore, November, 2017.

**NC4.** I. Das, **M. Sahoo**, P. Roy and H. Rahaman, ``A 45 uW 13 pJ/conv-step 7.4 ENOB 40 kS/s SAR ADC for Digital Microfluidic Biochip Applications", International Symposium on VLSI Design and Test (VDAT) 2014, PSG College of Technology, Coimbatore, <https://doi.org/10.1109/ISVDAT.2014.6881068>.

**NC3.** M. Guha, A. Sengupta, **M. Sahoo** and H. Rahaman, "Effect of Defects on Performance and Signal Integrity of Multilayer GNR Interconnects", INUP Familiarization Workshop on Compact Modeling, IISc, August, 2014.

**NC2. M. Sahoo** and B. Amrutur, ``Comparison of OpAmp Based and Comparator Based Switched Capacitor Filter," International Symposium on VLSI Design and Test (VDAT), 2012, Kolkata, Springer LNCS, vol. 7373, pp. 180-189, [https://doi.org/10.1007/978-3-642-31494-0\\_21](https://doi.org/10.1007/978-3-642-31494-0_21).

**NC1. M. Sahoo**, and H. Rahaman, "Analytical Modeling of Crosstalk Effects in Coupled Copper Interconnects in Deep Sub Micron Technology", IEEE CODEC, IRPE, Calcutta University, India, pp. 1-4, Dec. 17–19, 2012, <https://doi.org/10.1109/CODEC.2012.6509212>.

 06-08-2024